

Global Dossier

Immediate access to patent application dossiers, also known as "file wrappers", from the world's largest patent offices all in one place

NEW: now extended to authorities participating in the WIPO CASE initiative, such as the Canadian Intellectual Property Office and the WIPO IB itself

Why use Global Dossier?

- immediate access to critical business information when it becomes available
- mitigating your risk when your competitor has filed an application for a patent that could have an impact on your business
- ability to follow the patent applications through every step of the procedure until grant and to decide how to react
- advantage in business: confidence in knowing you have the most up-to-date information

Access and more

www.epo.org/register www.epo.org/espacenet

Global Dossier in a nutshell

- inspection of patent files in China, Japan, Korea, the US, Canada, at the WIPO International Bureau (IB) and at the EPO through one service
- machine translation into English
- free of charge
- available through the Global European
 Patent Register and Espacenet
- will be extended to cover further offices (Australia, Israel and UK in the near future)

Using Global Dossier

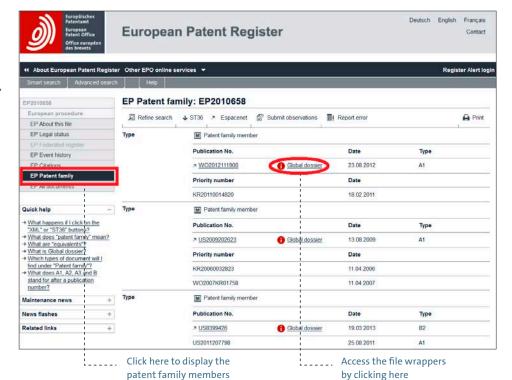
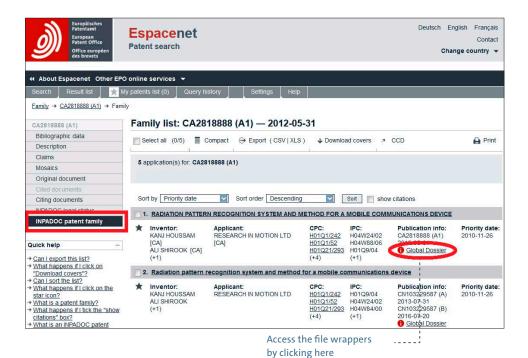


Figure 1:
Example of Global Dossier in the European Patent
Register, showing links to the file wrappers for patent family members

Figures 2 and 3: In **Espacenet** you can find the Global Dossier icon both in the bibliographic view and in the INPADOC patent family view





Office	Documents in Global Dossier
EPO	Patent applicationsfiled on or after 1 June 1978
JPO	Patent and utility model applications filed after 2003
	PCT international applications entering the national phase in Japan after 2005
KIPO	Patent and utility model applications filed from January 2000 onwards
SIPO	Patent applications filed on or after 10 February 2010
USPTO	Patent applications filed from January 2003 onwards
CIPO	Patent applications published on or after 1 January 2008
WIPO IB	PCT patent applications published on or after 1 January 1978

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